

INSULATOR–TO–METAL SWITCH VIA THE FIELD–DRIVEN COLLAPSE OF THE MOTT GAP

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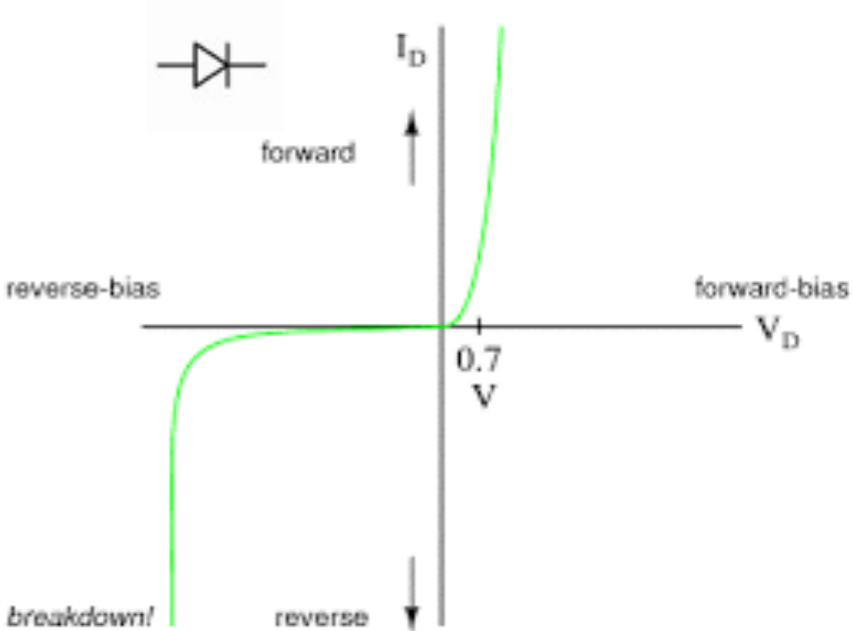
International School for Advanced Studies @ Trieste

arXiv 1602.03138

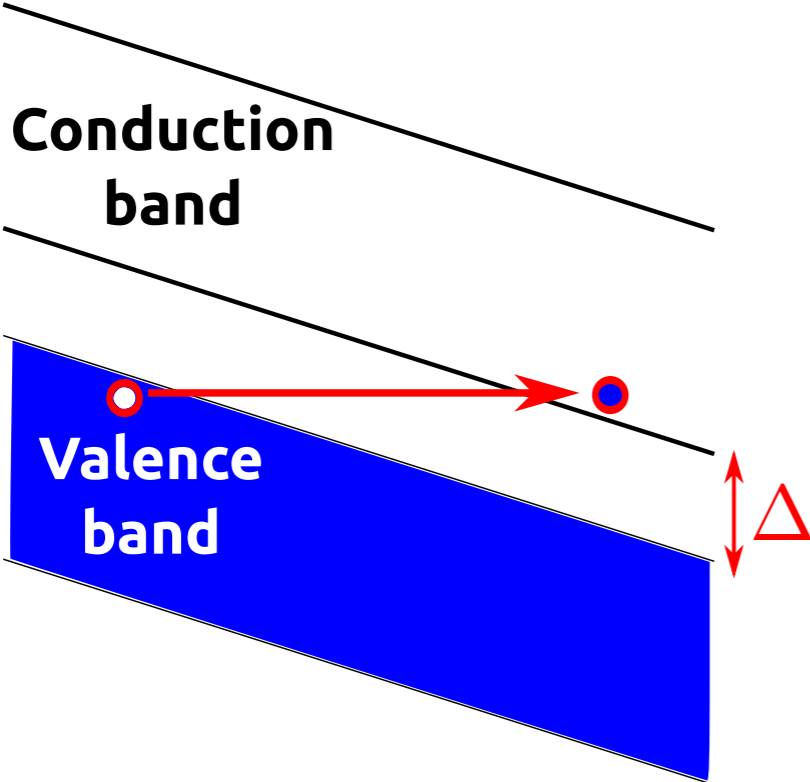
NGSCES 2016, Trieste

Control of the conductive properties of materials

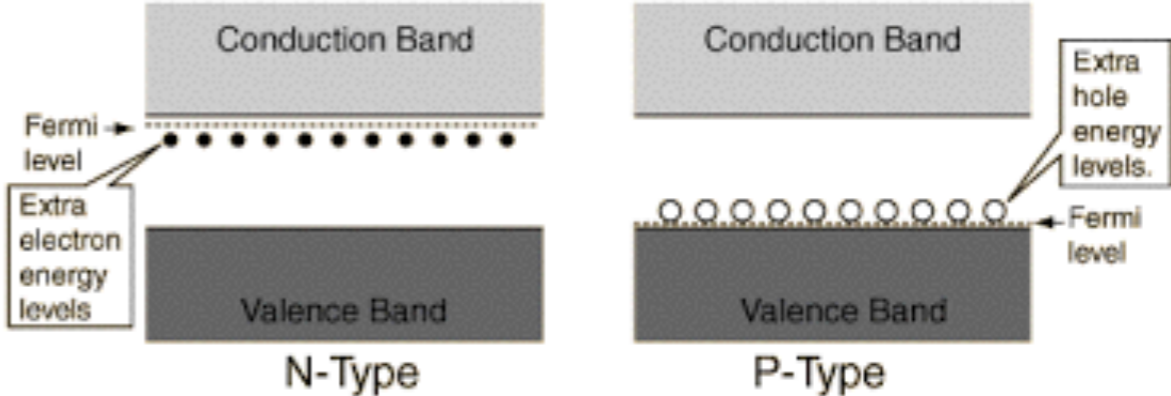
Semiconductor based electronic devices



* Quantum tunneling



* Chemical doping

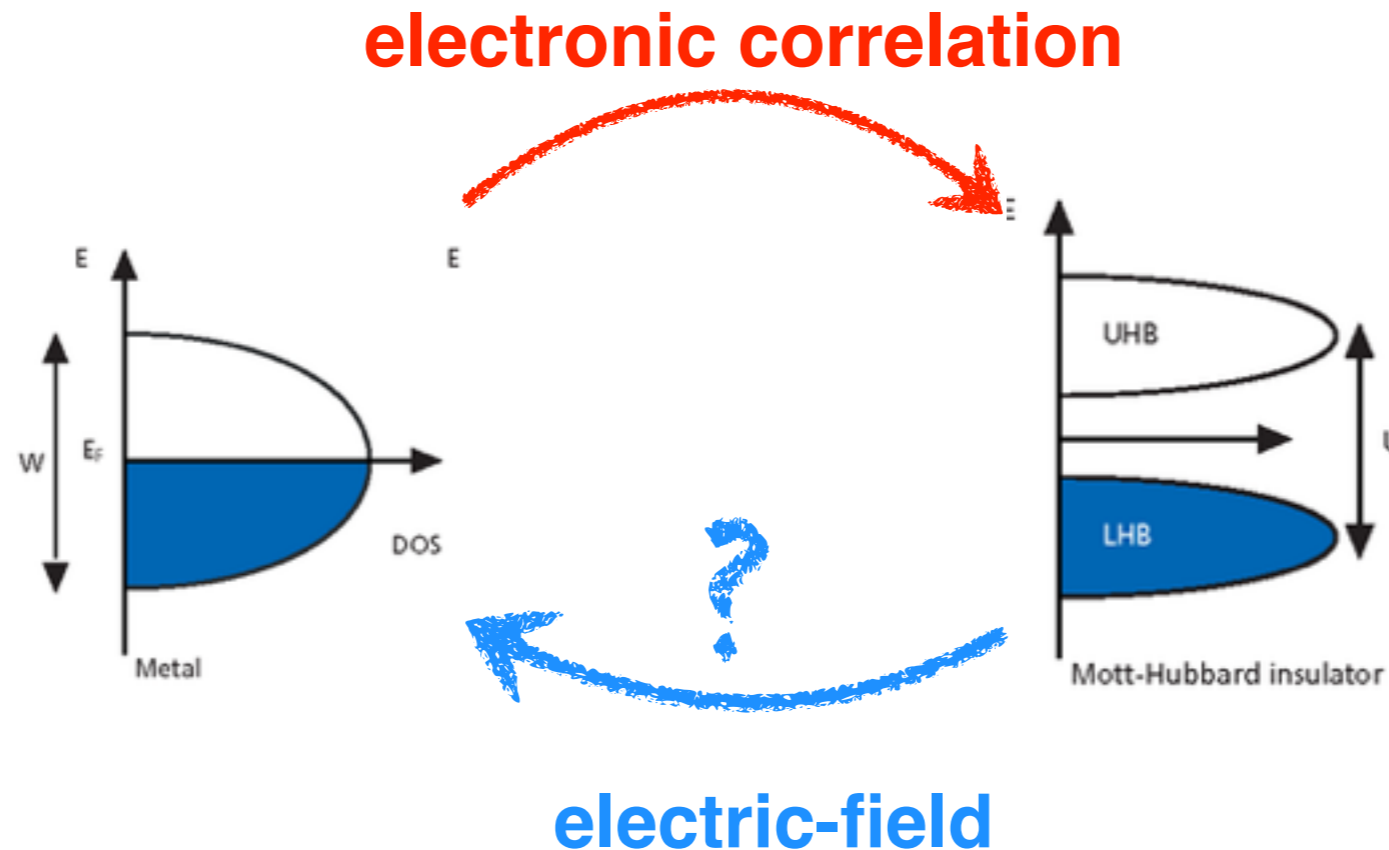


Why Correlated Materials?

“unsuccessful
metals”



Mott insulators



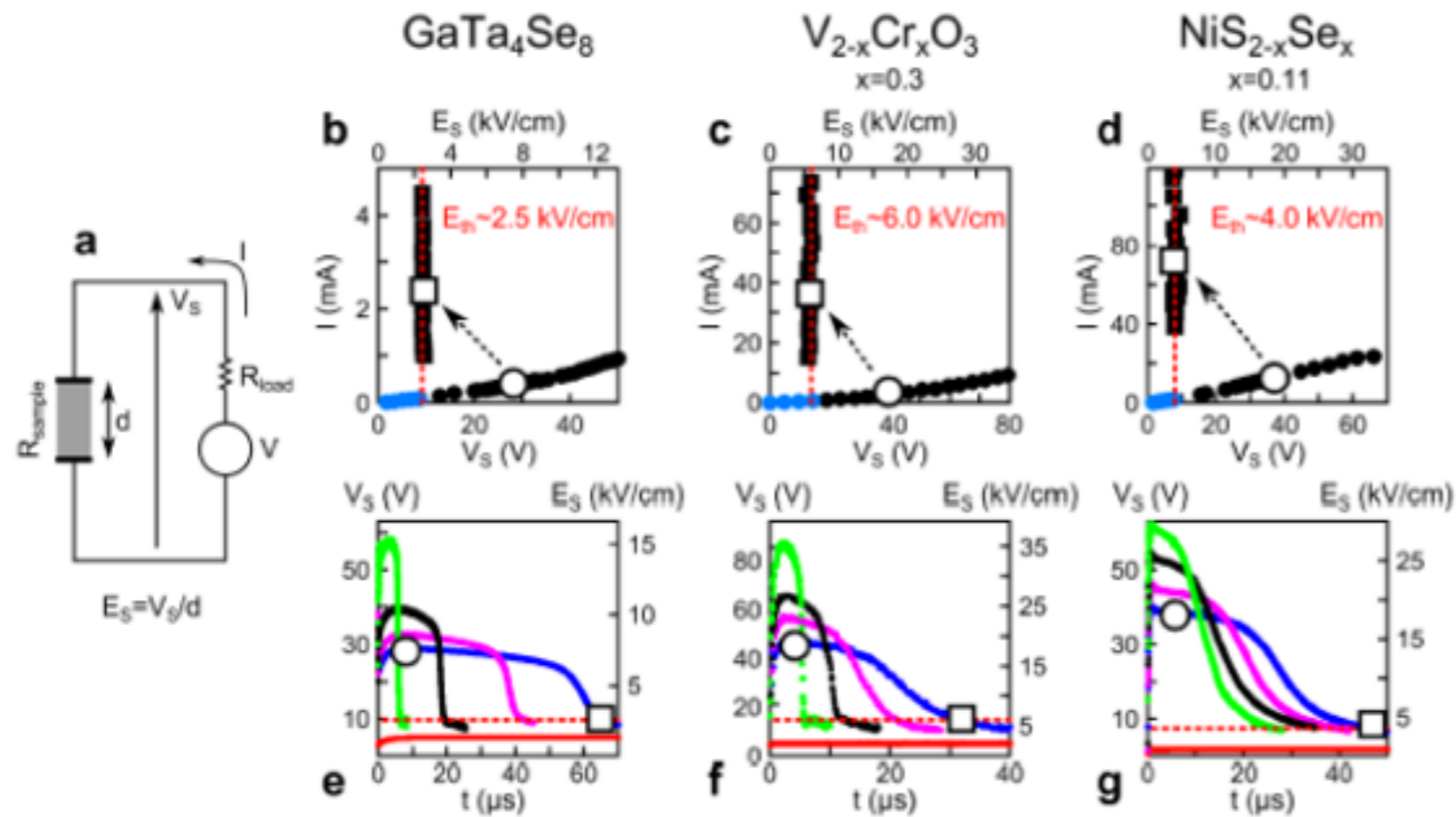
Unlock a huge number of frozen carriers

Huge potential for Mott based microelectronic devices!

Inoue & Rozenberg Adv. Funct. Mater. '08
Janod et al Adv. Funct. Mater. '15,

Insulators-to-Metal switch in correlated insulators

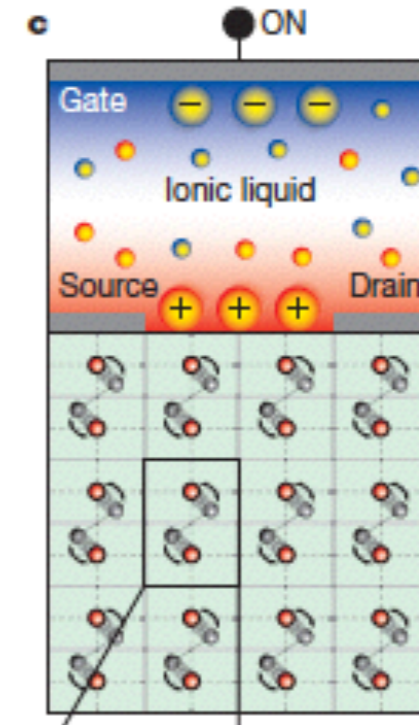
Resistive switch experiments



Abrupt switch at fields much smaller than the gap

Guiot et al NatComm '13
Stoilar et al AdvMat '13

Electric-Double-Layer-Transistor



VO_2

bulk delocalisation above the electrostatic screening length

Nakano et al Nature '12

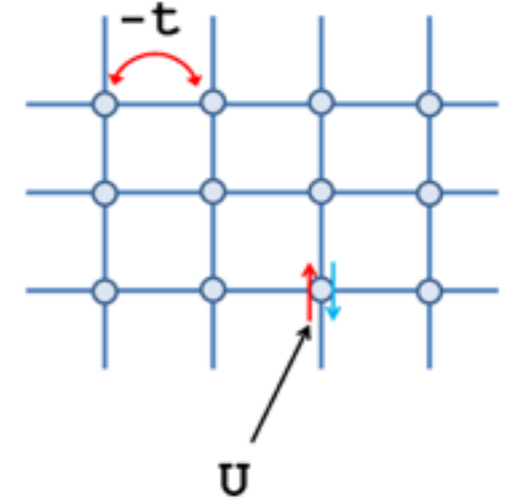
Insulators-to-metal switch beyond semiconductor physics

Breakdown in Mott-Hubbard Insulators

Simplest description of a correlated insulator

dielectric breakdown

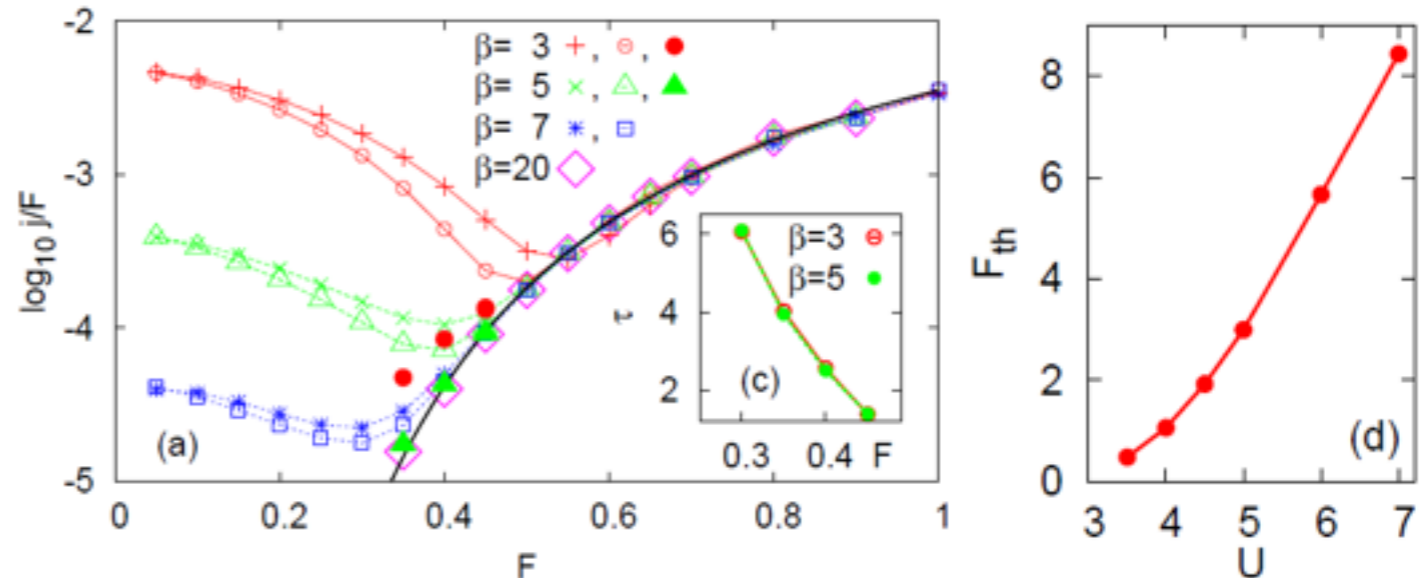
not too different from semiconductors!



* Tunnel across the Mott-Hubbard gap

- T. Oka et al PRL '03
- S. Okamoto PRB '08
- M. Eckstein et al PRL '10
- M. Eckstein et al. PRB '14
- G. Mazza et al. PRB'15

Eckstein et al PRL 105, 146404

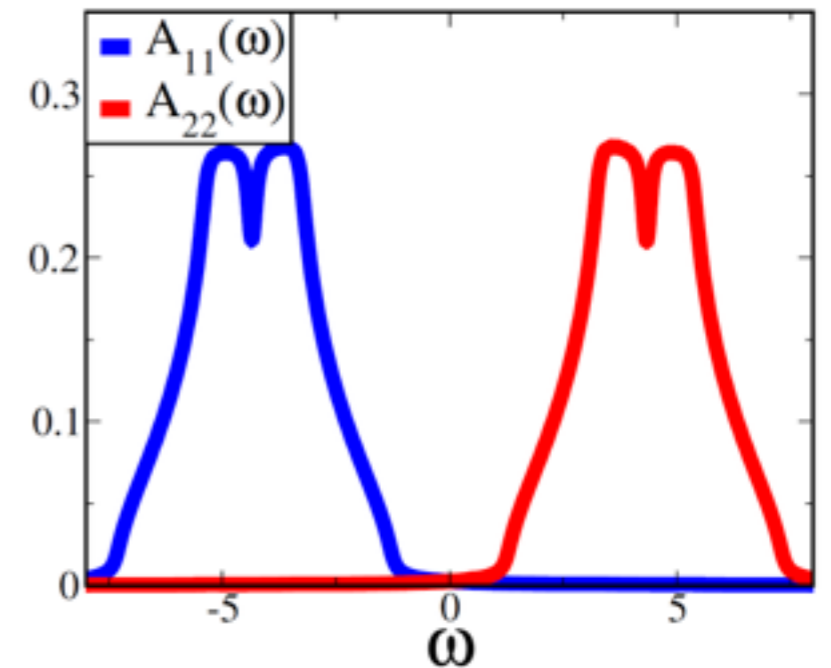
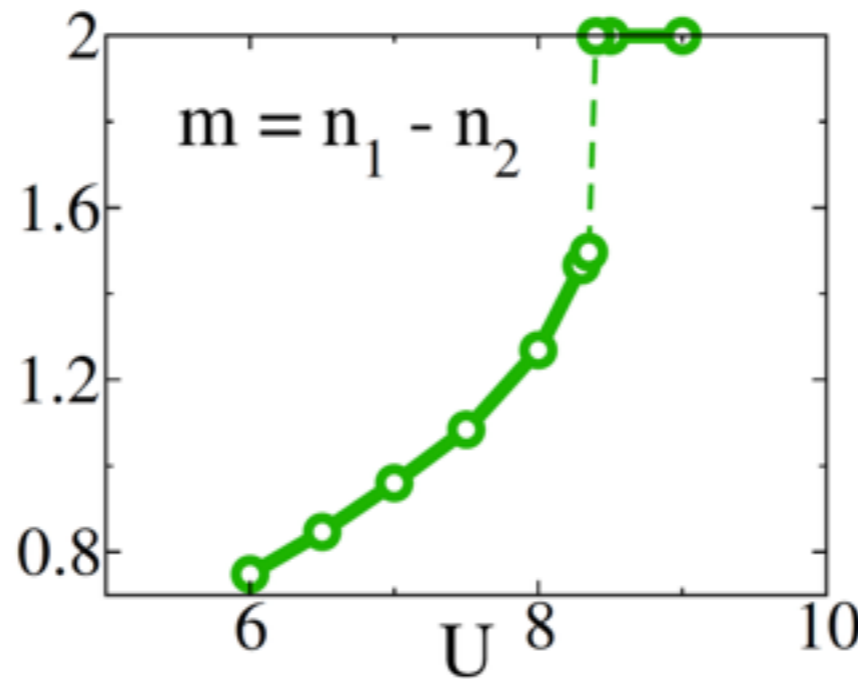
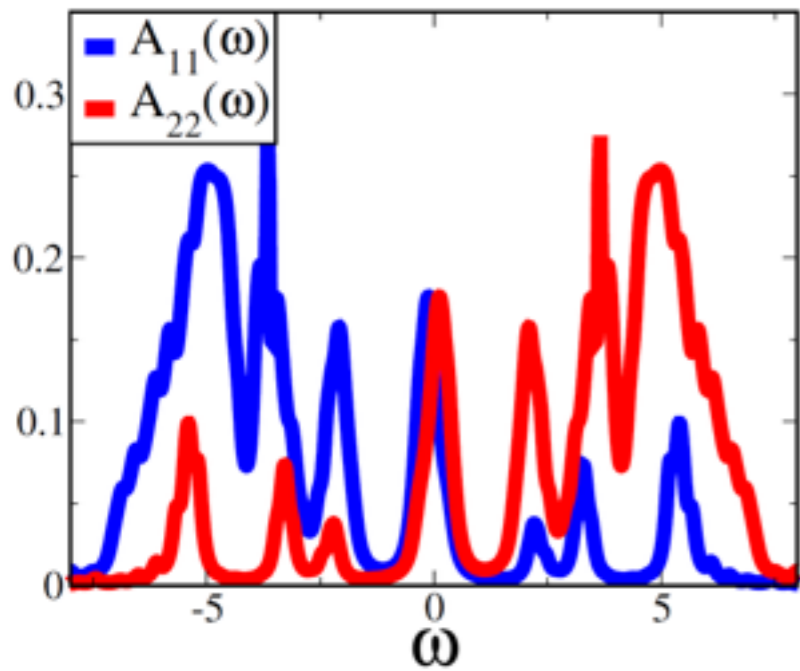
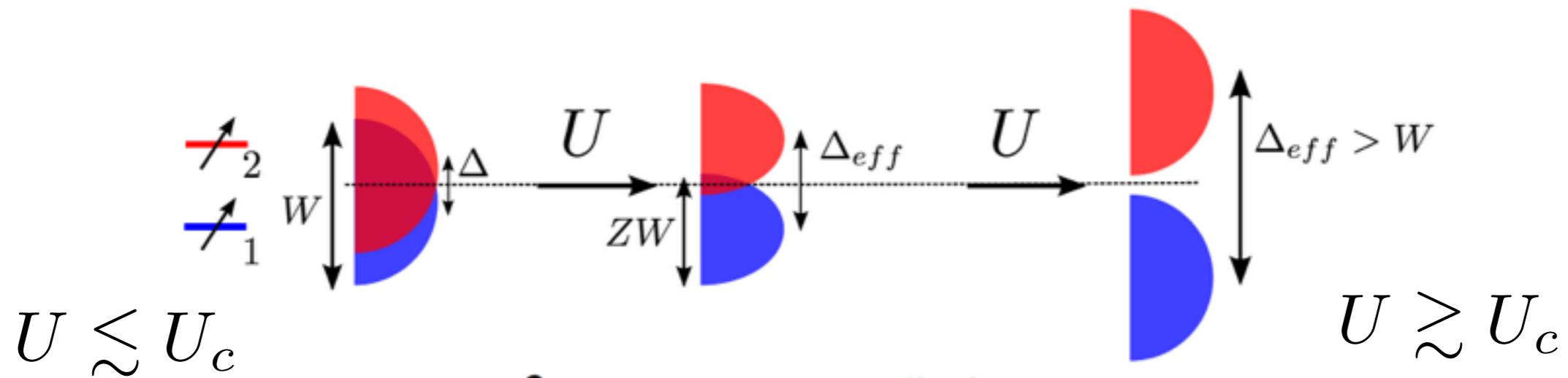


Possible alternative route to the dielectric breakdown

Mott insulator coexisting with a metastable metal

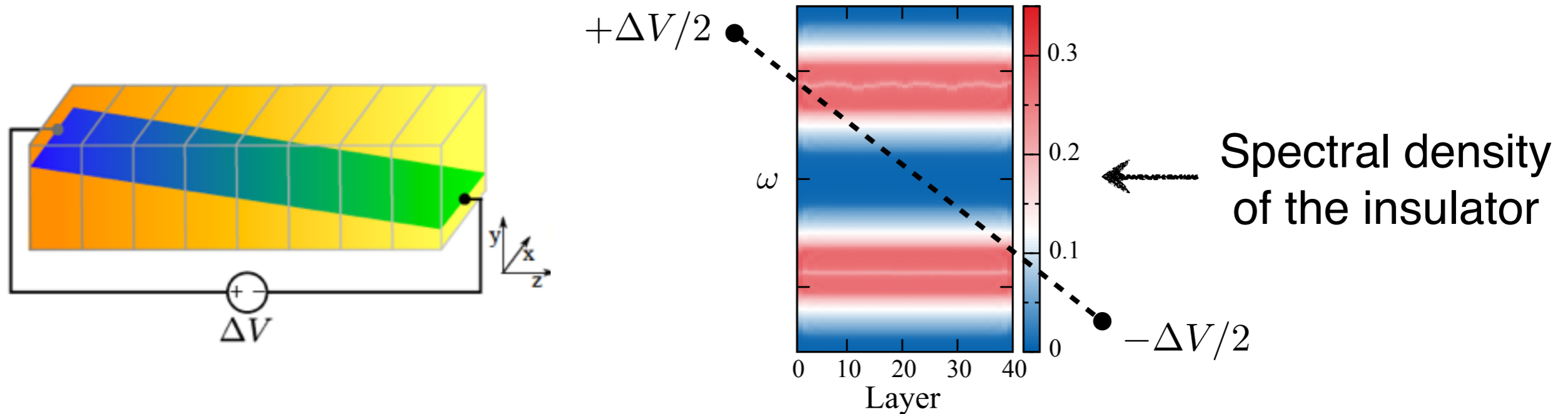
Model: Two bands + crystal field + U

Effects of e-e correlation \rightarrow Shrinking coherent quasiparticles $W \rightarrow ZW$
 \rightarrow Enhancement of the crystal field $\Delta \rightarrow \Delta + Um$

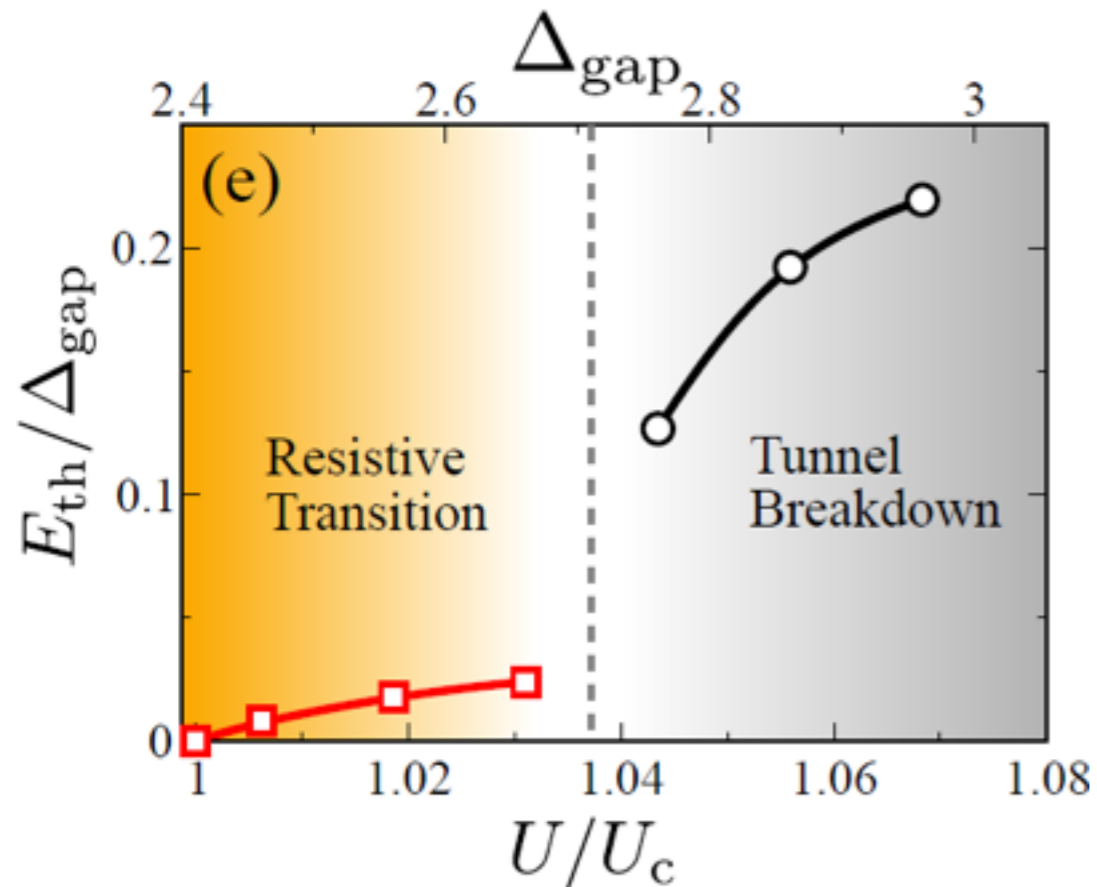


First-order MIT (DMFT)
Metal-Insulator Coexistence

Insulating slab w/ applied electric field



Ground state evolution across the field driven insulator-to-metal transition (real space DMFT)



**Different mechanisms
IN and OUT
the metal-insulator
coexistence region!**

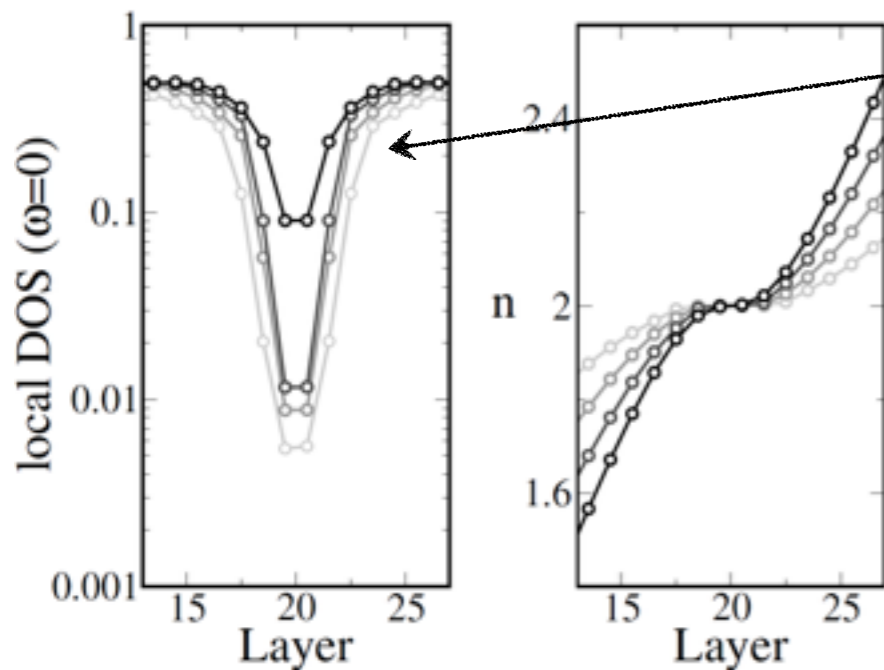
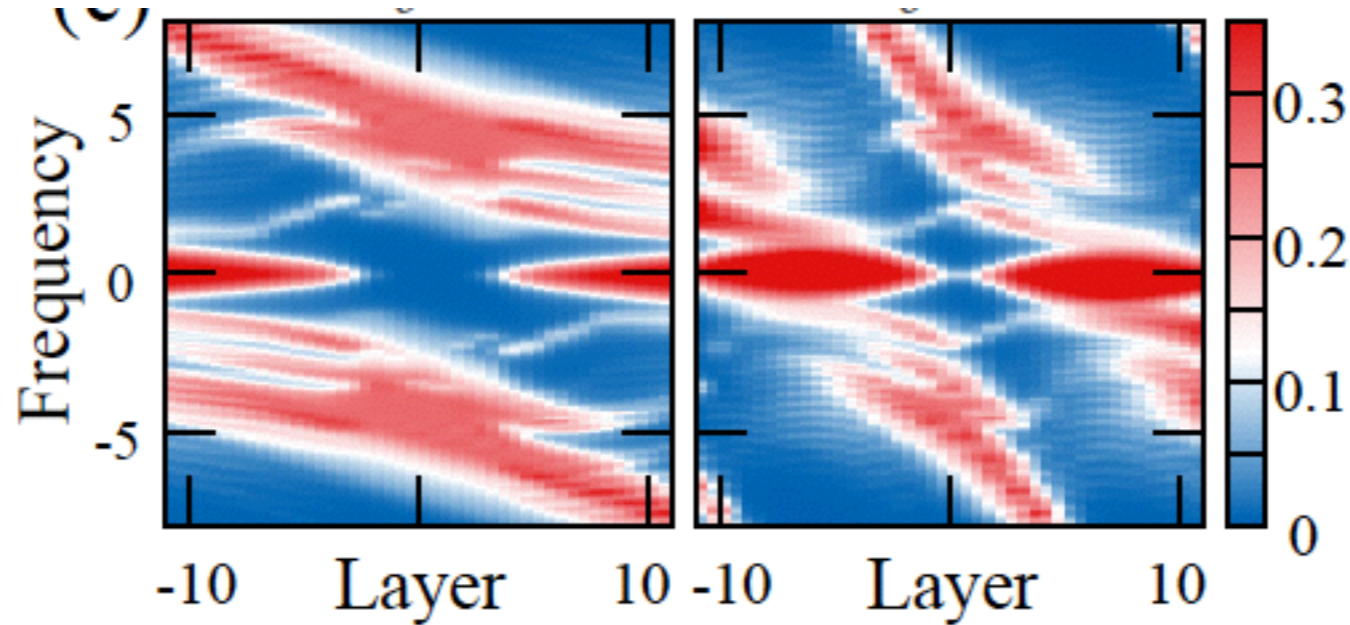
Field-induced insulator-to-metal transition

$$U \gg U_c$$

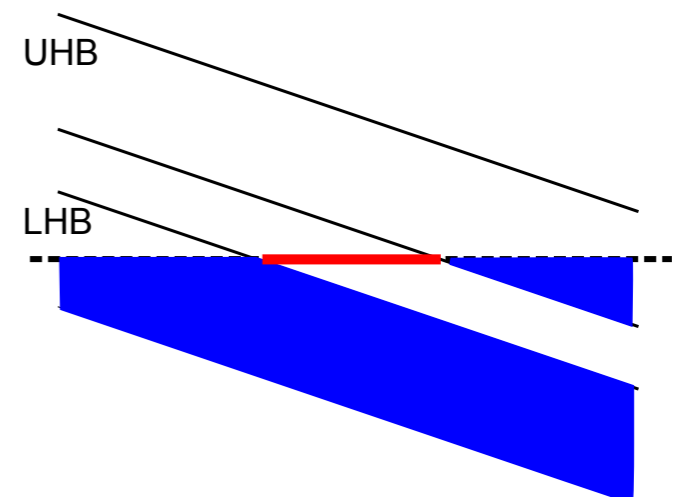
increasing Electric Field



Rigid tilt of the insulating gap



- * inhomogeneous metal
- * charge redistribution



“equilibrium picture” of tunnel-like conductive channel

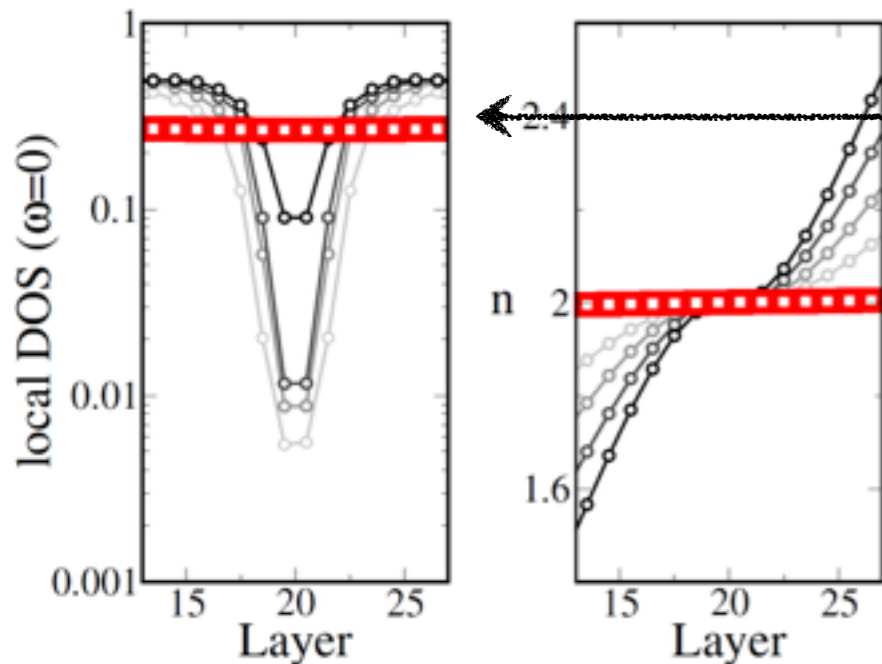
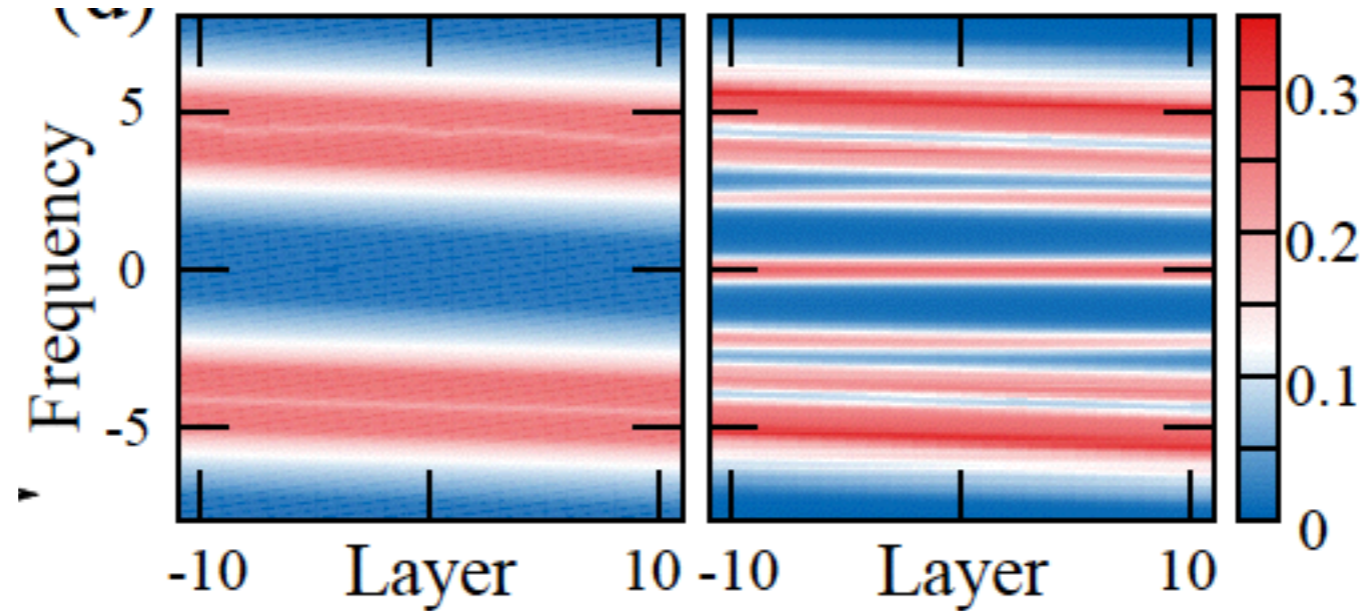
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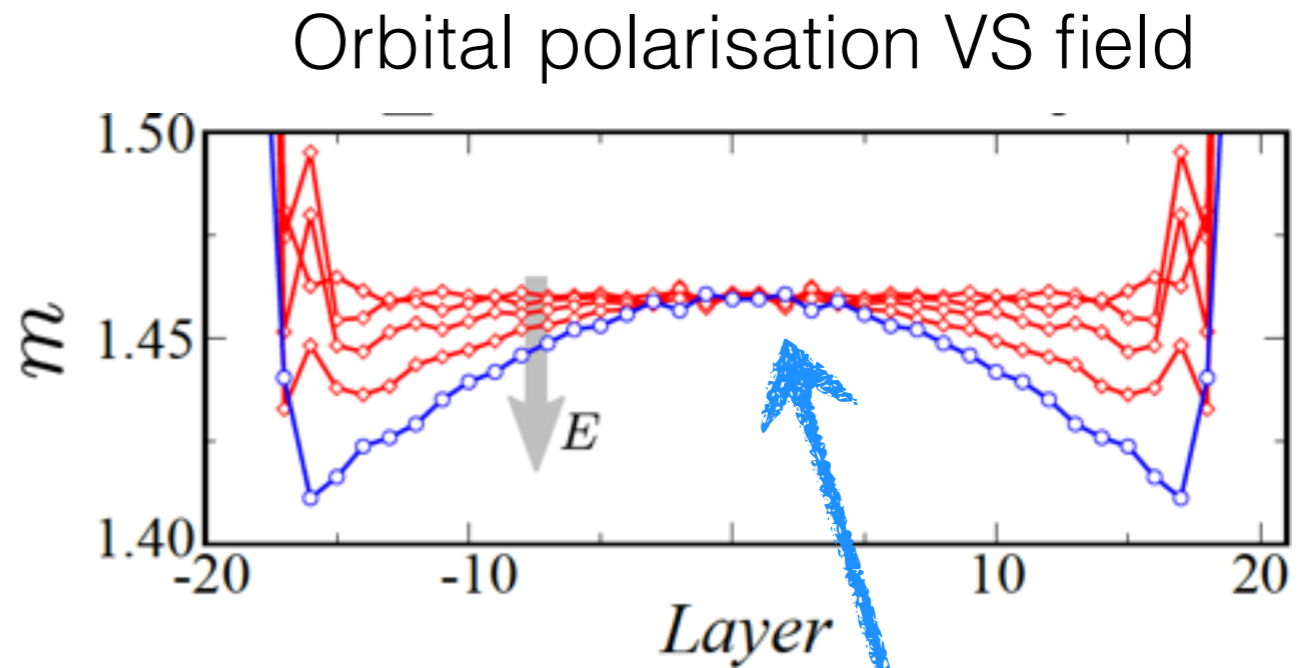
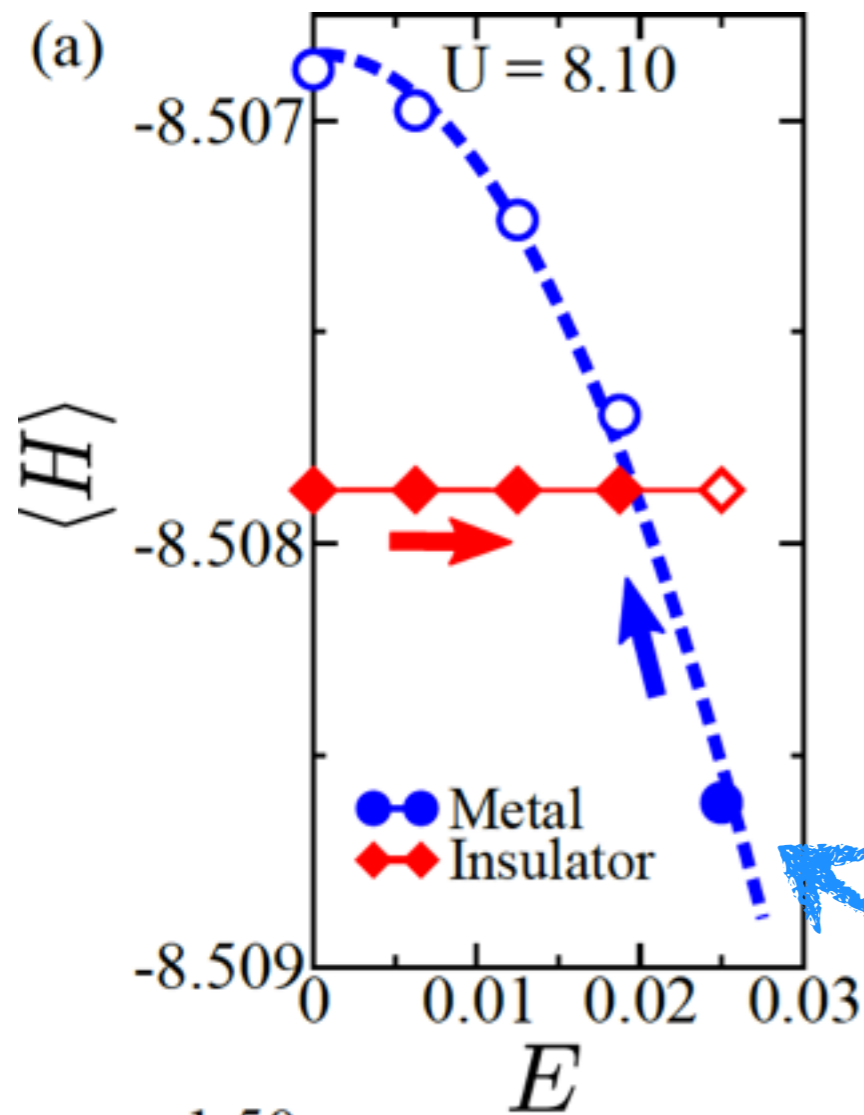
Abrupt closing
of the gap



- * Homogenous conductive states
- * No charge redistribution

**First-order
insulator-to-metal transition!**

INS-MET hysteresis loop VS electric field



The electric field reduces the effect of correlations

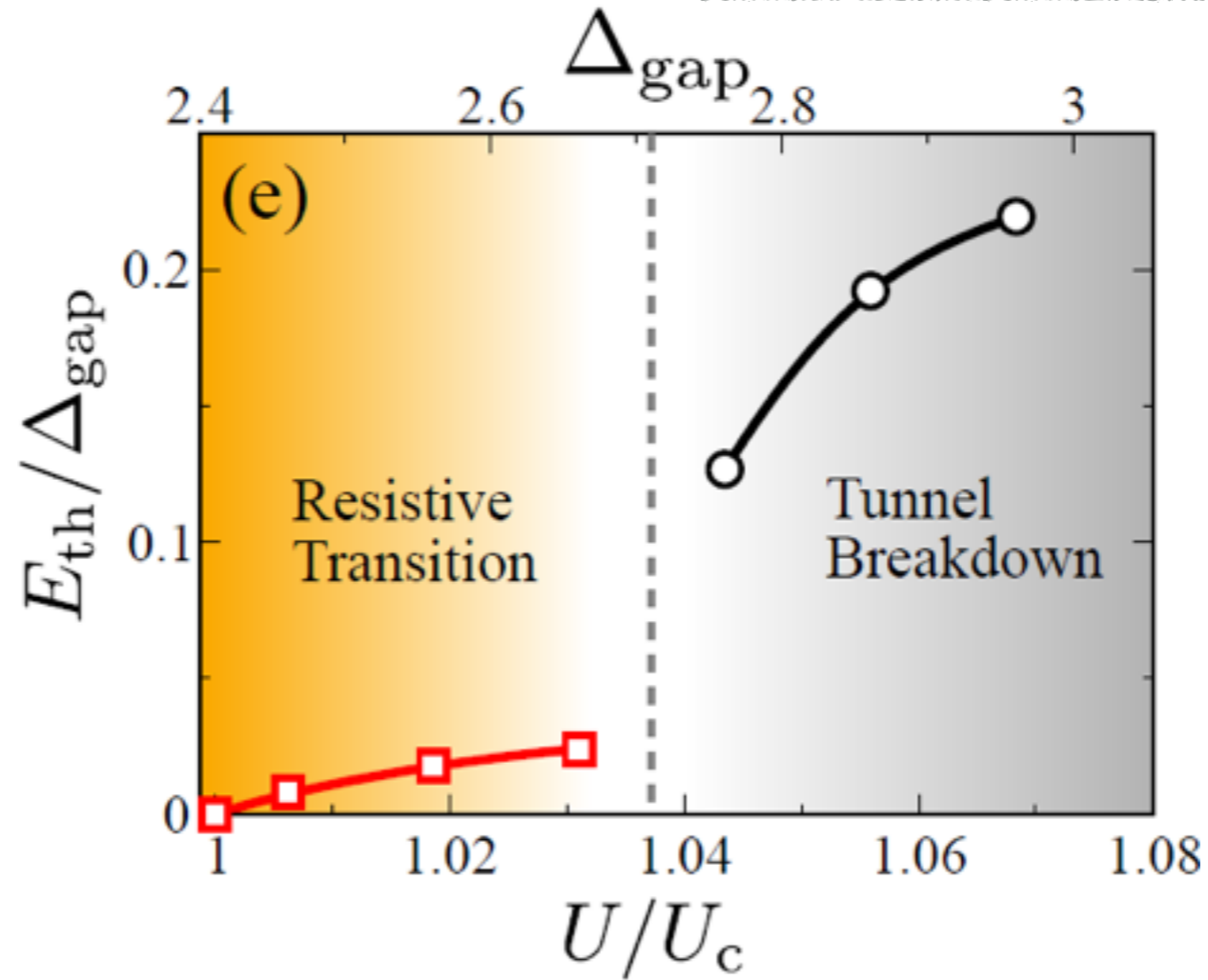
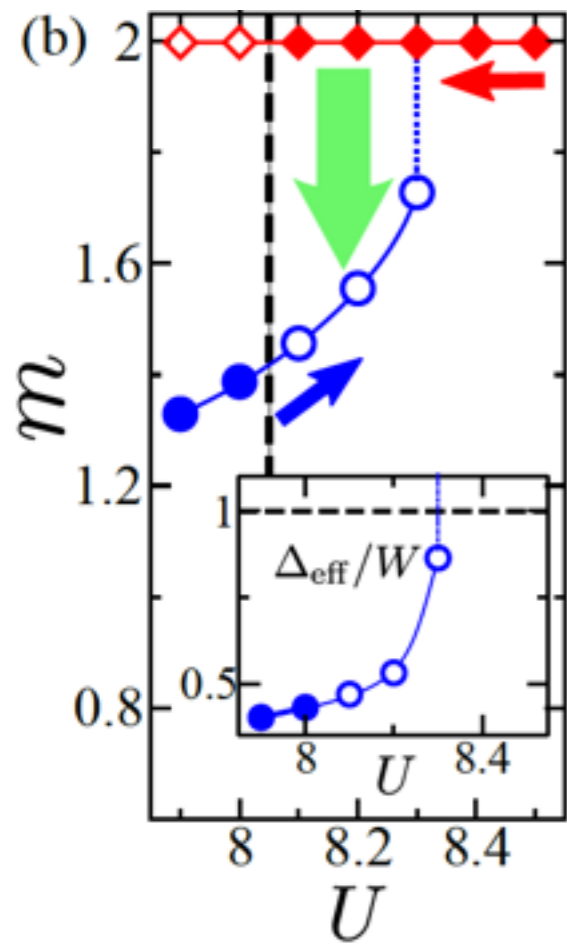
Energy gain within the linear response regime

$$\delta \langle H \rangle \propto E^2$$

Relatively small electric field is able to induce the switch between the two competing phases!

Different routes for the Mott insulator metallisation

Rigid modification of the insulator (only one stable phase)

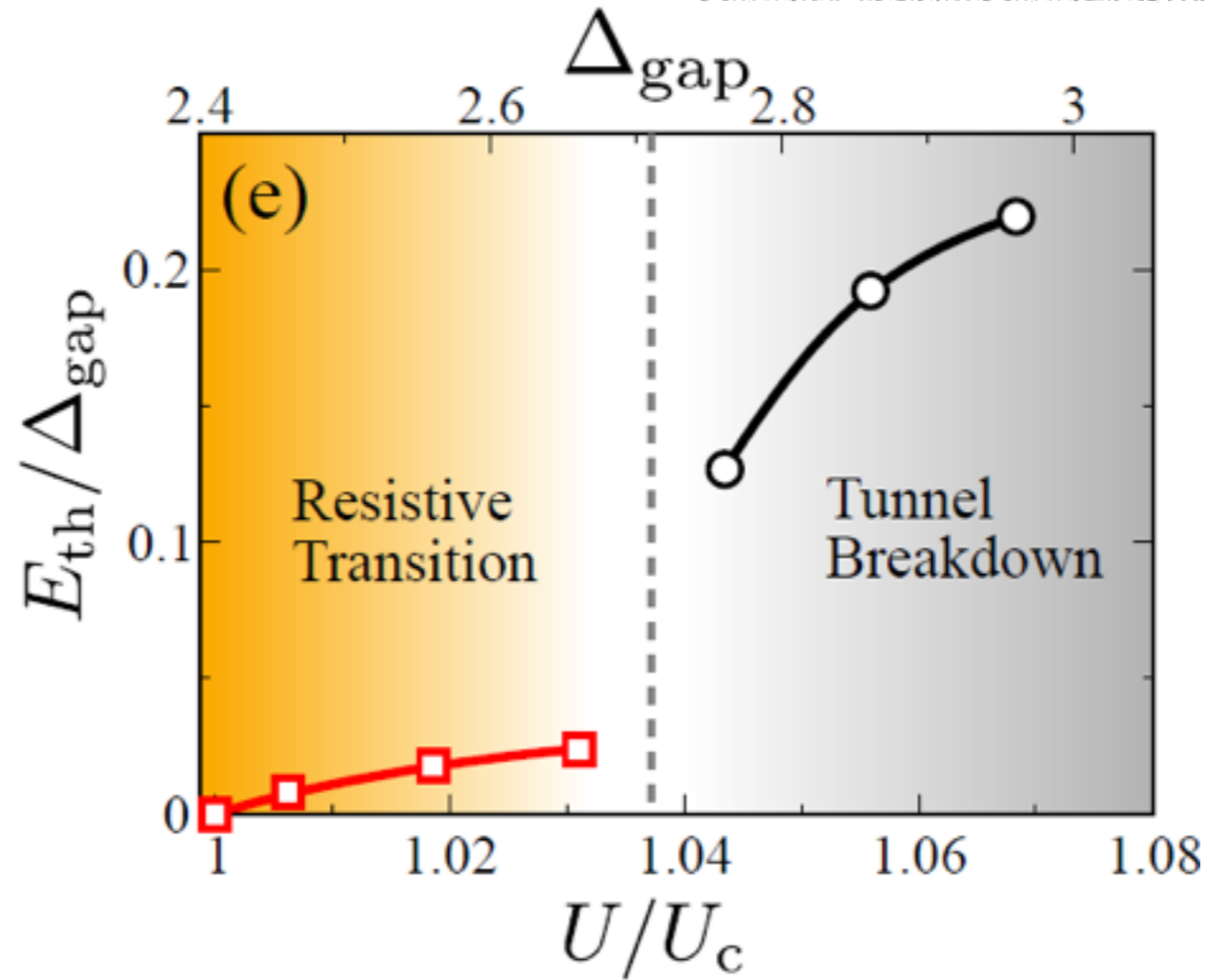
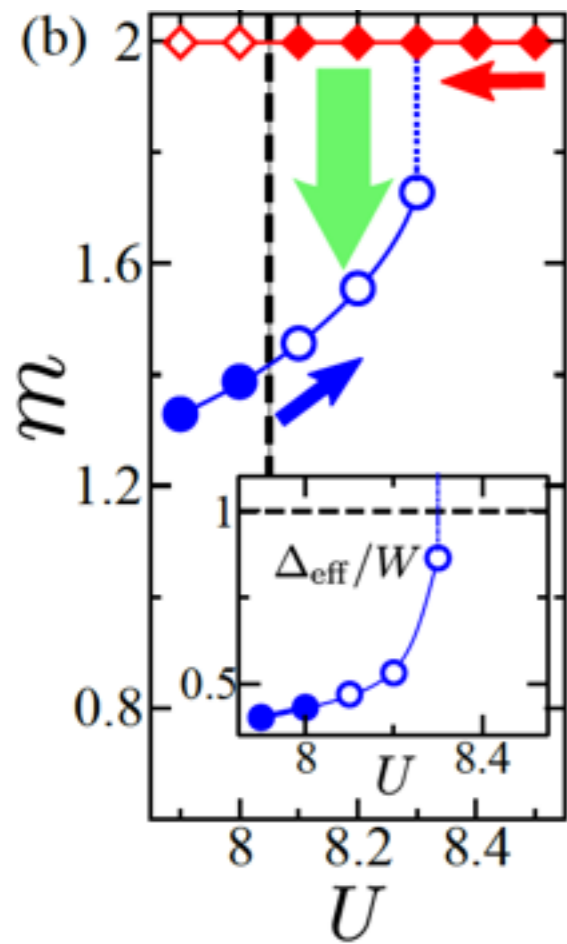


Switch between two competing phases

Qualitative and quantitative different IMT!

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Switch between two competing phases

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Thank you